

Spin and pseudo-spin states in silicon for QC: lifetimes

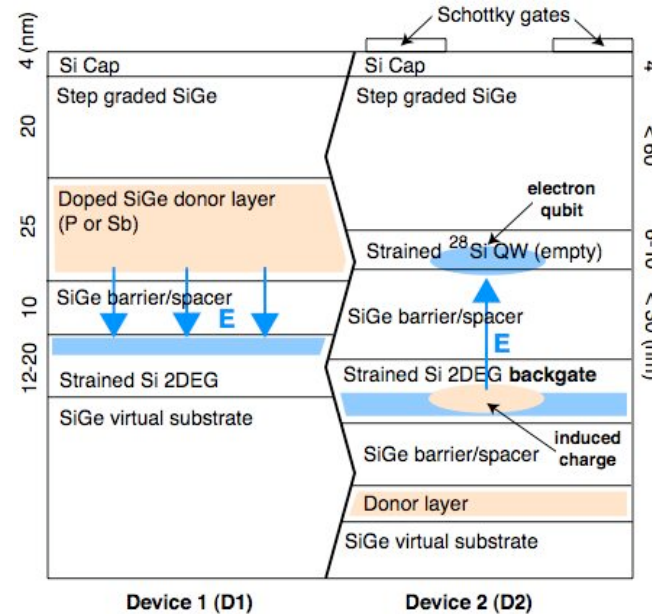


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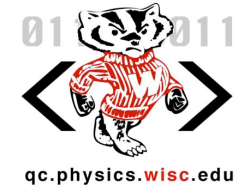
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Wisconsin-Madison*

and

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Mark Friesen
S. N. Coppersmith
J. Truitt
M. A. Eriksson
et. al.*

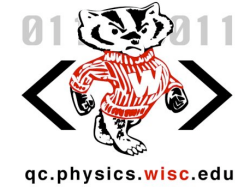


New theory results for silicon



- 1. 2DEG spin relaxation:** *Correct anisotropy and magnitudes.
Times will increase with mobility and B.*
- 2. Rashba Coefficient:** $\alpha \approx 1 - 6 \text{ m/s}$
- 3. T_1 in Si quantum dots:** *Rashba SOC usually dominates.
Time increases with smaller dots
and smaller B-fields.*
- 4. Valley-state lifetimes:** *Microseconds to milliseconds.
Long-lived pseudo-spin states.*

SiGe quantum wells for QDQC

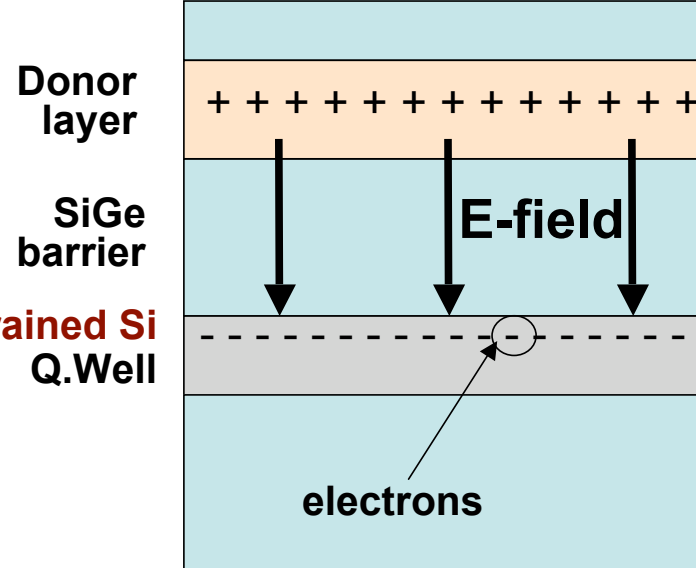


Our device:

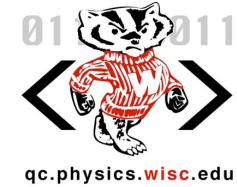
$$n_s = 4 \times 10^{11} \text{ e/cm}^2$$
$$\mu = 40,000 \text{ cm}^2/\text{Vs}$$
$$E = 6 \times 10^6 \text{ V/m}$$

Pure **strained Si**
Q.Well

Typical SiGe Device

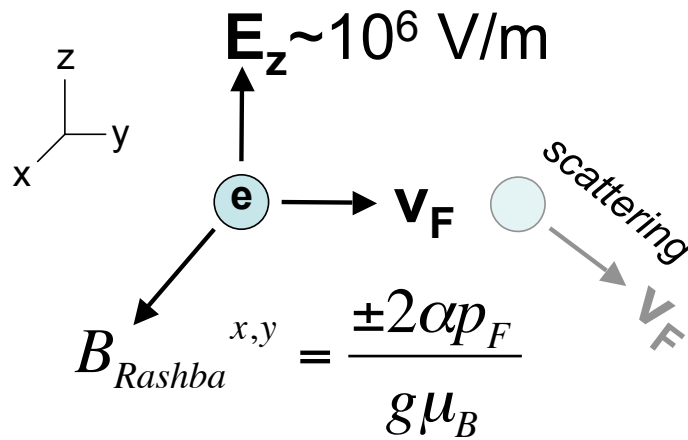


Spin relaxation in SiGe 2DEGs

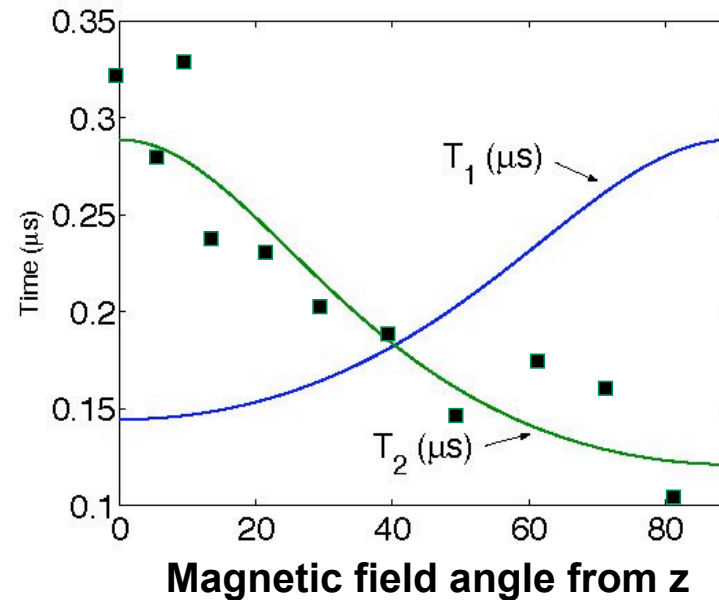


- Rashba SOC + scattering = fluctuating **B-field in-plane**
- Anisotropic T_1 and T_2

T ~ 5 K



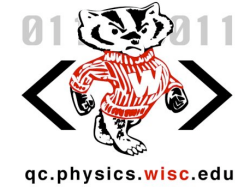
General range: $\frac{1}{T_1} \approx \frac{1}{T_2} \approx 0.1 - 20 \mu\text{s} \sim \alpha^2$



Tahan and Joynt, condmat/0401615

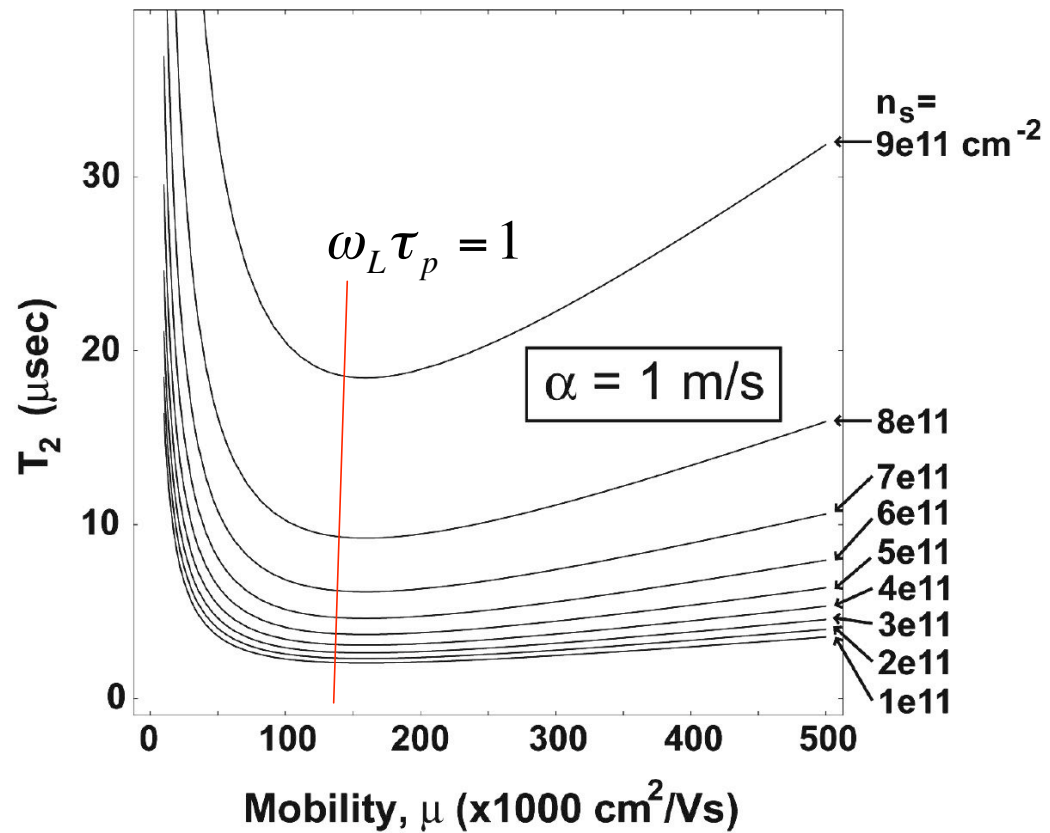
T_1 & T_2 increase with mobility

...in high mobility limit

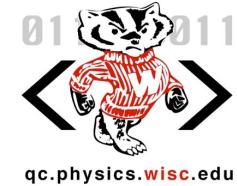


- In a static B-field

$$\omega_L = \frac{g\mu B}{\hbar}$$



Rashba coefficient in silicon



- Spin-orbit coupling due to large E_z

$$H_{Rashba} = \alpha(p_x \sigma_y - p_y \sigma_x)$$

- Kane-like 8 band calculation for Si

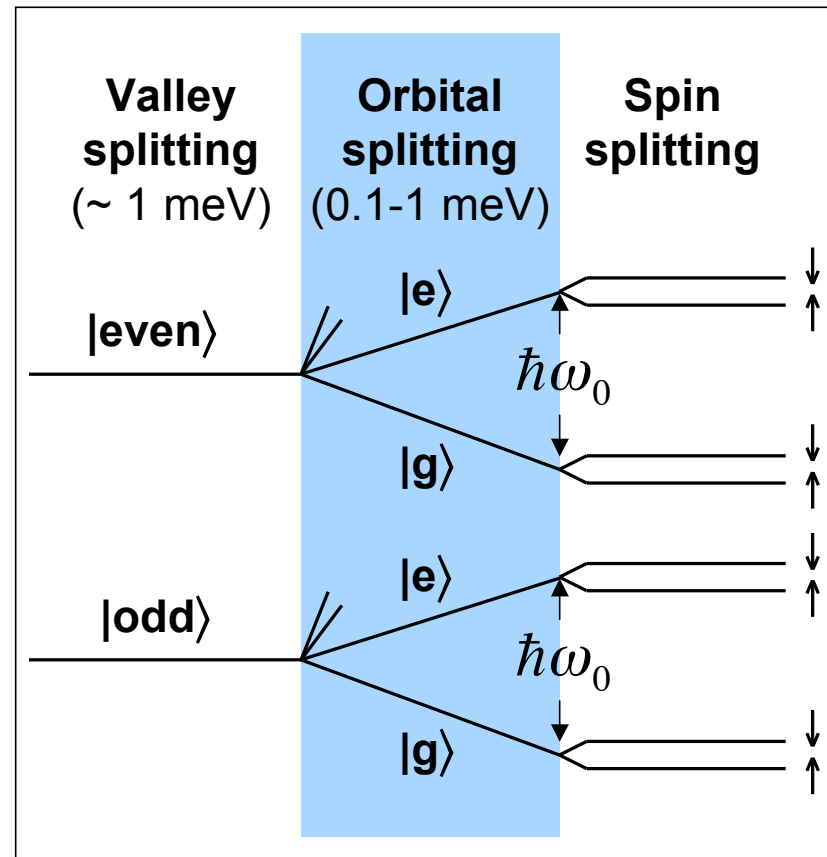
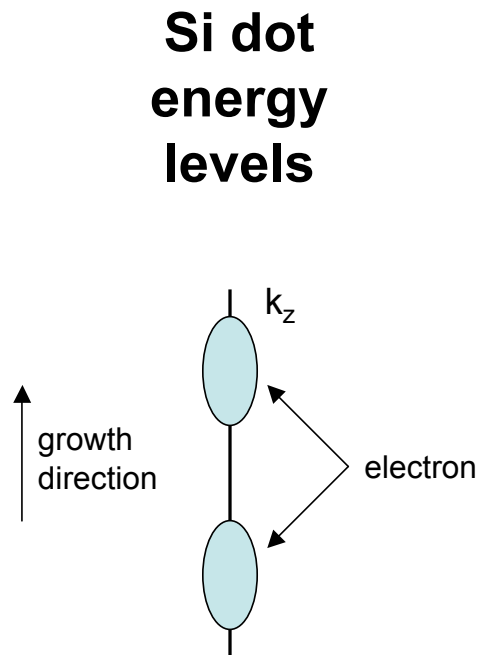
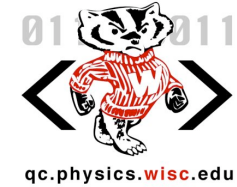
$$\alpha(\mathbf{E}_z) \approx \sqrt{2} \frac{PP_z \Delta_d}{\hbar} \frac{e}{(E_{v1} + \Delta_d)^2 E_{v2}} \mathbf{E}_z$$

Our theory: $\alpha \approx 1 - 6 \text{ m/s}$

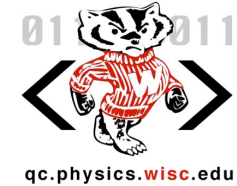
Rashba spin-splitting: $\Delta_R \sim 1 \mu\text{eV}$
Rashba field: $B_R^{x,y} = 10 - 40 \text{ G}$

In-line with experimental evidence.

SiGe QW quantum dot



T₁ from Rashba in Si QDs

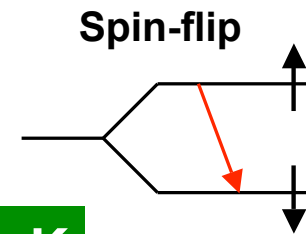


- **Confined state:** $\langle \mathbf{p}_{x,y} \rangle \ll p_F^{2DEG} \Rightarrow$ **2DEG mechanism gone**
- **Rashba spin-orbit mixing + phonon = relaxation**

$$\frac{1}{T_1} \sim \frac{E_u^2}{v_t^7} \frac{\alpha^2}{(\hbar\omega_0)^4} B^7$$

unexpected: GaAs and bulk Si: $\sim (g\mu B)^5$

Dot size dependent

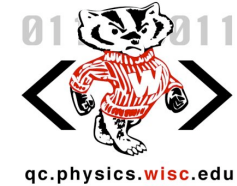


T < 100 mK

- **Non-zero for all directions of B**

T_1	$B = 0.33 \text{ T}$	$B = 2 \text{ T}$
$\hbar\omega_0 = 0.1 \text{ meV}$	5 s	0.002 s
$\hbar\omega_0 = 1 \text{ meV}$	56,000 s	24 s

Orbital relaxation in strained Si



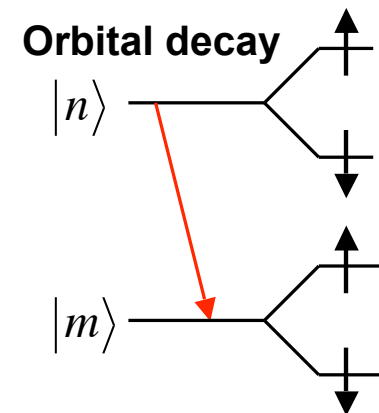
- Deformation interaction (no piezo-phonons in Si)
- Strained Si => transverse phonons contribute

$$\Gamma_{mn}(\text{s}^{-1}) \sim \left| \langle m | z | n \rangle \right|^2 \frac{E_{mn}^5}{v_t^7}$$

transverse phonons: $v_t = v_l / 2$

- Speed comparable to GaAs

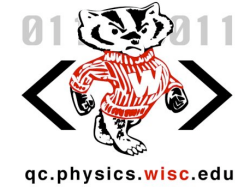
$$\Gamma_{mn}(\text{s}^{-1}) \approx \text{ns to ps} \quad (\hbar\omega_0 = 0.1 - 1 \text{ meV})$$



Relevant to:

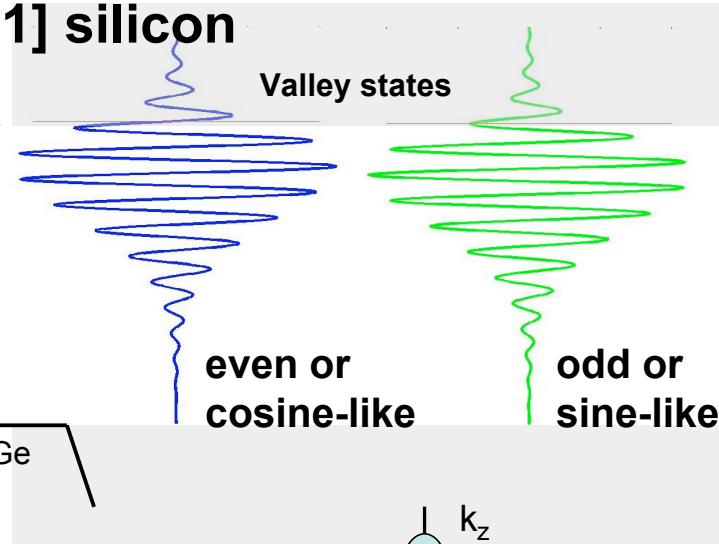
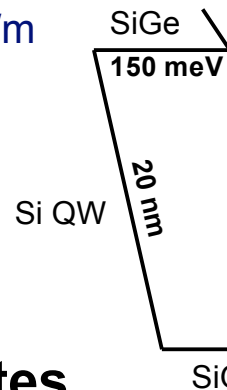
- Optical pumping/ Initialization
- Many-phonon processes

Valley states in silicon QWQDs

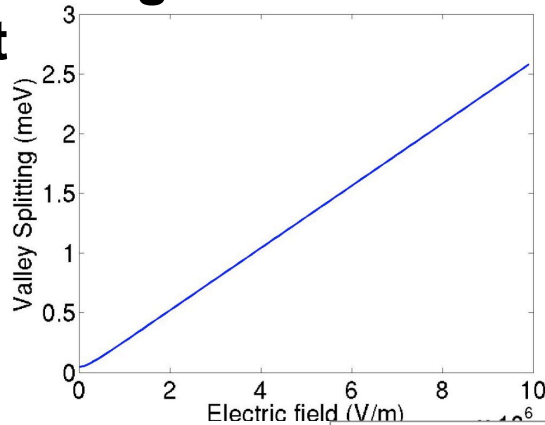


- 2-valley nature of strained [001] silicon

$E \sim 6 \times 10^6 \text{ V/m}$

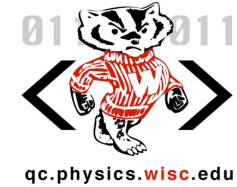


- Valley-splitting isolates spin qubit



Boykin, Klimeck, Coppersmith, *et. al.*, APL **84**, 115 (2003)

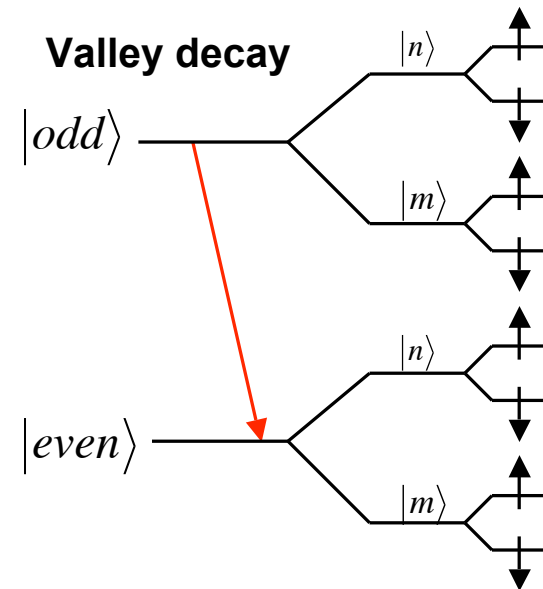
Valley-state lifetimes



- Same procedure as orbital relaxation
- Extremely small electric-dipole matrix element

$$\Gamma_{mn}^v (s^{-1}) \approx \text{microsecs - millisecs}$$

- Long relaxation times for non-spin-flip transitions
- Tunable with external E-field



We have calculated for *silicon*...

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Times will increase with mobility and B.*

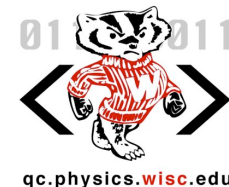
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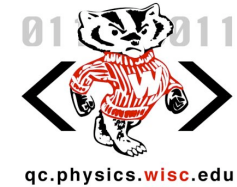
More info at...

cond-mat/? - coming soon...
cond-mat/0401615
cond-mat/0304422 - PRL
cond-mat/0203319 - PRB



<http://qc.physics.wisc.edu/>

Orbach spin relaxation



- Two phonon process
- Dominant mechanism in P:Si for $T > 4$ K
- Provides limited spectroscopy of first orbital energy gap

$$\frac{1}{T_1} \approx M^2_{SO} \Gamma_{1 \rightarrow g} e^{-E_{1g}/kT}$$

Relaxation rate of level $|1\rangle$
 SO mixing between $|1\rangle$ and $|g\rangle$
 Phonon DOS

